

Appl. No.	:	10/046,594
Applicant	:	Stephen Y. Chou
Filed	:	October 29, 2001
Title	:	IMPROVED RELEASE SURFACES, PARTICULARLY FOR USE IN NANOIMPRINT LITHOGRAPHY
TC/A.U.	:	1732
Examiner	:	M. Vargot
Docket No.	:	UNMN 9372D1

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Commissioner for Patents
PO Box 1450
Alexandria, VA 22313-1450

AMENDMENT AFTER FINAL REJECTION

Sir:

In response to the Office Action of July 10, 2007, along with payment of all extension of time fees, please enter the following:

Amendment of the Claims begin on page **2** of this paper.

Remarks/Arguments begin on page **15** of this paper.

I hereby certify that this correspondence is being filed via EFS-Web with the United States Patent and Trademark Office on January 10, 2008.

Mark E. Books
Mark E. Books, Reg. No. 40,918